Contents

**Part I Introductory Concepts, Characterization
and Optimization Strategies**

1 Fundamentals of Femtosecond Laser Modification of Bulk Dielectrics	3
Shane M. Eaton, Giulio Cerullo, and Roberto Osellame	
1.1 Introduction	3
1.2 Femtosecond Laser–Material Interaction	4
1.2.1 Free Electron Plasma Formation	4
1.2.2 Relaxation and Modification	7
1.3 Exposure Variables and Considerations.....	11
1.3.1 Focusing	11
1.3.2 Writing Geometry.....	13
1.3.3 Influence of Exposure Variables Within Low- and High-Repetition Rate Regimes	14
1.4 Summary	16
References	16
2 Imaging of Plasma Dynamics for Controlled Micromachining.....	19
Jan Siegel and Javier Solis	
2.1 Introduction	19
2.2 Assessment of the Interaction of Ultrashort Pulses with Dielectrics Using Optical Probes	20
2.2.1 Interaction Mechanisms and Characteristic Time Scales	20
2.2.2 Time-resolved Optical Techniques	22
2.2.3 Exploiting Spatial Resolution	23
2.2.4 Basic Models for Quantitative Analysis of Experimental Data	25

2.3	Ultrafast Imaging at the Surface of Dielectrics	27
2.3.1	Experimental Configurations and Constraints	27
2.3.2	Transient Plasma Dynamics and Permanent Material Modifications	29
2.4	Ultrafast Imaging in the Bulk of Dielectrics	32
2.4.1	Experimental Configurations and Constraints	32
2.4.2	Transient Plasma Dynamics in Glasses Under Waveguide Writing Conditions: Role of Pulse Duration, Energy, Polarization, and Processing Depth	35
2.5	Outlook and Conclusions	38
	References	40
3	Spectroscopic Characterization of Waveguides	43
	Denise M. Krol	
3.1	Introduction	43
3.2	Spectroscopic Analysis of Glass	44
3.2.1	Fluorescence Spectroscopy	44
3.2.2	Raman Spectroscopy	47
3.2.3	Confocal Imaging	49
3.3	Experimental Equipment and Procedures	49
3.3.1	Femtosecond Laser Systems and Micromachining Procedures	50
3.3.2	Confocal Microscope System and Spectroscopy Procedures	51
3.4	Spectroscopic Analysis of fs-laser Modification in Fused Silica	52
3.4.1	Fluorescence Spectroscopy and Imaging of Waveguides and Bragg Gratings	52
3.4.2	Photobleaching of Defects	55
3.4.3	Raman Spectroscopy and Imaging	55
3.5	Spectroscopic Analysis of Waveguides in Phosphate Glasses	57
3.5.1	Fluorescence Spectroscopy and Imaging of IOG-1	57
3.5.2	Comparison of Waveguides in Fused Silica and IOG-1	59
3.5.3	Raman Spectroscopy and Imaging of Rare Earth-doped Phosphate Glass	60
3.6	Summary	63
	References	63

4	Optimizing Laser-Induced Refractive Index Changes in Optical Glasses via Spatial and Temporal Adaptive Beam Engineering	67
	Razvan Stoian	
4.1	Introduction	67
4.2	Mechanisms of Laser-Induced Refractive Index Changes	69
4.3	Experimental Implementations for Pulse Engineering	73
4.3.1	Spatio-Temporal Beam Shaping	73
4.3.2	Microscopy Based Adaptive Loops	75
4.4	Material Interaction with Tailored Pulses	76
4.4.1	Refractive Index Engineering by Temporally Tailored Pulses	76
4.4.2	Energy Confinement and Size Corrections	78
4.4.3	Adaptive Correction of Wavefront Distortions	80
4.4.4	Dynamic Parallel Processing	84
4.5	Outlook and Conclusions	87
	References	88
5	Controlling the Cross-section of Ultrafast Laser Inscribed Optical Waveguides	93
	Robert R. Thomson, Nicholas D. Psaila, Henry T. Bookey, Derryck T. Reid, and Ajoy K. Kar	
5.1	Introduction	93
5.2	The Effect of the Waveguide Cross-section on the Properties of the Guided Modes	94
5.3	The Importance of Controlling the Waveguide Cross-section from a Device Engineering Perspective	97
5.3.1	Effect of Mode Field Distribution on Waveguide Coupling Loss	97
5.3.2	Effect of Mode Field Distribution on Waveguide Propagation Loss	98
5.3.3	Effect of Mode Field Distribution on Evanescent Coupling	99
5.3.4	Effect of Waveguide Asymmetry on Polarisation Dependent Guiding Properties	100
5.4	Experimental Techniques for Measuring the Refractive Index Profile of Ultrafast Laser Inscribed Waveguides	100
5.4.1	Refracted Near-field (RNF) Method	100
5.4.2	Micro-reflectivity	101
5.4.3	Quantitative Phase Microscopy	102
5.4.4	Inverse Helmholtz Technique	104

5.5	Effect of Inscription Parameters on the Waveguide Cross-section	105
5.6	Experimental Techniques for Controlling the Waveguide Cross-section	108
5.6.1	The Astigmatic Beam Shaping Technique	108
5.6.2	The Slit Beam Shaping Technique	111
5.6.3	Waveguide Shaping Using Active Optics	114
5.6.4	Spatiotemporal Focussing	118
5.6.5	The Multiscan Technique	120
5.7	Conclusions and Outlook	121
	References	122
6	Quill and Nonreciprocal Ultrafast Laser Writing	127
	Peter G. Kazansky and Martynas Beresna	
6.1	Introduction	128
6.2	Quill Writing	128
6.3	Anisotropic Bubble Formation	137
6.4	Nonreciprocal Writing	139
6.5	Conclusion	149
	References	150

Part II Waveguides and Optical Devices in Glass

7	Passive Photonic Devices in Glass	155
	Shane M. Eaton and Peter R. Herman	
7.1	Introduction	155
7.2	Characterization of Femtosecond Laser-Written Waveguides	157
7.2.1	Microscope Observation	158
7.2.2	Insertion Loss	158
7.2.3	Mode Profile and Coupling Loss	159
7.2.4	Propagation Loss	160
7.2.5	Refracted Near Field Method	161
7.3	Femtosecond Laser Microfabrication of Optical Waveguides	161
7.3.1	Low-Repetition Rate Regime	162
7.3.2	High-Repetition Rate Regime	164
7.4	Devices	172
7.4.1	Y-Junctions	173
7.4.2	Directional Couplers	175
7.4.3	Mach–Zehnder Interferometers	186
7.4.4	Other Devices	186
7.5	Summary and Future Outlook	192
	References	193

8	Fibre Grating Inscription and Applications	197
	Nemanja Jovanovic, Alex Fuerbach, Graham D. Marshall, Martin Ams, and Michael J. Withford	
8.1	Introduction	197
8.2	Review of Gratings Types	199
8.2.1	Long Period Gratings	199
8.2.2	Fibre Bragg Gratings	200
8.3	Point-by-Point Inscribed Gratings	202
8.3.1	Fabrication Methods	202
8.3.2	Development of Femtosecond Laser Direct-Write LPGs	204
8.3.3	Development of Femtosecond Laser Direct-Write FBGs	205
8.4	Phase Mask Inscribed Gratings	206
8.4.1	Fabrication Method	206
8.4.2	Development of Femtosecond Laser-Phase Mask Inscription	207
8.5	Properties of Femtosecond Laser Written Gratings	209
8.5.1	Thermal Stability	209
8.5.2	Stress and Birefringence	212
8.5.3	Photoattenuation	214
8.6	Applications	216
8.6.1	Fibre Lasers	216
8.6.2	Sensors	218
8.6.3	Other Applications	220
8.7	Novel Fibre Types and Challenges	220
8.7.1	Microstructured Optical-Fibres (MOFs)	220
8.7.2	Polymer and Non-linear Fibres	222
8.7.3	Through Jacket Grating Writing	222
8.8	Summary	222
	References	223
9	3D Bragg Grating Waveguide Devices	227
	Haibin Zhang and Peter R. Herman	
9.1	Introduction	227
9.2	Bragg Grating Waveguide Fabrication	230
9.2.1	BGW Fabrication Method 1: Single-pulse Writing	231
9.2.2	BGW Fabrication Method 2: Burst Writing	238
9.2.3	BGW Thermal Stability	244
9.3	BGW Devices	247
9.3.1	Multi-wavelength BGWs	247
9.3.2	Chirped BGWs	250
9.3.3	3D BGW Sensor Network	253
9.4	Summary and Future Outlook	259
	References	261

10 Active Photonic Devices	265
Giuseppe Della Valle and Roberto Osellame	
10.1 Introduction	265
10.2 Active Ions for Waveguide Devices	266
10.3 Gain Definitions and Measurement Technique	270
10.3.1 Definition of the Main Figures of An Active Waveguide	270
10.3.2 The On/Off Technique for Gain Measurement	274
10.4 Active Waveguides and Amplifiers	277
10.4.1 Internal Gain in Nd-Doped Active Waveguides	277
10.4.2 Waveguide Amplifier in Er:Yb-Doped Phosphate Glass	277
10.4.3 Waveguide Amplifier in Er:Yb-Doped Oxyfluoride Silicate Glass	278
10.4.4 Active Waveguides in New Glass Materials	281
10.5 Waveguide Lasers	281
10.5.1 Waveguide Lasers in Er:Yb-Doped Phosphate Glass	281
10.5.2 Waveguide Laser in Er:Yb-Doped Oxyfluoride Silicate Glass	283
10.6 Advanced Waveguide Lasers	283
10.6.1 Single-Longitudinal-Mode Operation	283
10.6.2 Mode-Locking Regime	288
10.7 Outlook and Conclusions	289
References	290

Part III Waveguides and Optical Devices in Other Transparent Materials

11 Waveguides in Crystalline Materials	295
Matthias Heinrich, Katja Rademaker, and Stefan Nolte	
11.1 Origins of Refractive Index Changes	295
11.2 Waveguides Characteristics in Various Crystals	298
11.2.1 Waveguide Fabrication in LiNbO_3	299
11.2.2 Other Crystals	300
11.2.3 Actively Doped Crystals and Ceramics	302
11.3 Nonlinear Properties	304
11.3.1 Lithium Niobate	304
11.4 Integrated Optical Devices	306
11.4.1 Mach-Zehnder Interferometer	306
11.4.2 Electrooptic Modulator	307
11.4.3 Waveguide Lasers	308
11.5 Conclusion	310
References	311

12	Refractive Index Structures in Polymers	315
	Patricia J. Scully, Alexandra Baum, Dun Liu, and Walter Perrie	
12.1	Introduction	315
12.2	Motivation for Refractive Index Structures in Polymers	316
12.3	Laser Photomodification of PMMA	317
12.3.1	Continuous Wave UV Laser Sources	317
12.3.2	Long Pulse (ns, ps) Laser Sources	317
12.3.3	Ultrashort fs Laser Sources	318
12.4	Waveguiding and Positive/Negative Refractive Index	319
12.5	Direct Writing	320
12.5.1	Simple Transmission Gratings (2D)	321
12.5.2	Production of Waveguides (1D)	322
12.6	Holographic Writing	323
12.7	Comparisons of Commercial and Clinical Grade PMMA	325
12.8	Pulse Duration, Wavelength, and Bandgap Dependence of Refractive Index Modification	325
12.8.1	Pulse Duration Dependence of Refractive Index Modification	326
12.8.2	Effect of Bandgap and Wavelength on Refractive Index Modification	331
12.9	Relating Photochemistry to Writing Conditions	332
12.9.1	Size Exclusion Chromatography	334
12.9.2	Thermal Desorption Volatile Analysis	334
12.9.3	Thermogravimetric Analysis	334
12.9.4	Optical Spectroscopy	335
12.9.5	Etching of Structures	335
12.9.6	Summary of Photochemical Analysis	336
12.10	Effect of Self-Focusing	336
12.11	Effects of Depth	339
12.12	Parallel Processing Using Spatial Light Modulator	340
12.13	Applications of Refractive Index Structures in Polymers	342
12.13.1	Polymer Optical Fibre Sensors and Devices	343
12.14	Summary	343
	References	344

Part IV Microsystems and Applications

13 Discrete Optics in Femtosecond Laser Written Waveguide Arrays...	351
Alexander Szameit, Felix Dreisow, and Stefan Nolte	
13.1 Introduction to Waveguide Arrays	351
13.2 Fundamental Principles of Discrete Light Propagation	353
13.3 Basic Experimental Techniques	355
13.3.1 Evanescent Coupling	355
13.3.2 Waveguide Imaging Microscopy	356
13.3.3 Multi-waveguide Excitation	357
13.4 Linear Propagation Effects	358
13.4.1 Straight Lattices	358
13.4.2 Curved Lattices	365
13.4.3 Quantum-Mechanical Analogies	370
13.5 Nonlinear Propagation Effects	373
13.5.1 Nonlinear Refractive Index	373
13.5.2 One-Dimensional Solitons	374
13.5.3 Two-Dimensional Solitons	381
13.6 Conclusions	385
References	386
14 Optofluidic Biochips	389
Rebeca Martínez Vázquez, Giulio Cerullo, Roberta Ramponi, and Roberto Osellame	
14.1 Introduction	389
14.2 Femtosecond Laser Microfluidic Channel Fabrication	392
14.2.1 Fundamental Physical Mechanisms	392
14.2.2 Microchannel Properties	394
14.2.3 Integration of Optical Waveguides and Microfluidic Channels	398
14.3 Integration of Photonic Sensors in LOCs	400
14.3.1 Cell Sorting	400
14.3.2 Microchip Capillary Electrophoresis	402
14.3.3 Label-Free Sensing with Mach–Zehnder Interferometers	405
14.4 Femtosecond Laser Fabrication of Optofluidic Devices	409
14.4.1 Flow Cytometry	409
14.4.2 Label-Free Sensing with Bragg Gratings	411
14.4.3 Cell Trapping and Stretching	413
14.5 Outlook and Conclusions	416
References	417

15	Microstructuring of Photosensitive Glass	421
	Koji Sugioka	
15.1	Introduction	421
15.2	Photosensitive Glass	422
15.2.1	Characteristics	422
15.2.2	Microstructuring Procedure	424
15.2.3	Microstructuring Mechanism.....	425
15.3	Fabrication of Microfluidic Structures	428
15.4	Fabrication of Micro-Optic Structures	430
15.4.1	Micro-Optics	430
15.4.2	Optical Waveguides.....	431
15.4.3	Integration of Optical Microcomponents	432
15.5	Fabrication of Microchip Devices.....	433
15.5.1	Microfluidic Dye Laser	433
15.5.2	Optofluidics	435
15.5.3	Nano-Aquarium	436
15.6	Summary	439
	References	439
16	Microsystems and Sensors	443
	Yves Bellouard, Ali A. Said, Mark Dugan, and Philippe Bado	
16.1	Introduction	443
16.2	Micro- and Nano-Systems.....	444
16.2.1	A Brief Overview of Microsystems	444
16.2.2	Issues on Microsystems Integration and Fabrication.....	444
16.3	Microsystems Fabricated Using Femtosecond Lasers: Review and State of the Art	446
16.3.1	Specificities of Femtosecond Laser–Matter Interaction from the View-Point of Microsystems Design	446
16.3.2	Integrated Optics Devices	447
16.3.3	Opto-Fluidics	448
16.3.4	Micromechanical Functionality	448
16.4	Multifunctional Monolithic System Integration	448
16.4.1	Concept.....	448
16.4.2	Taxonomy of Individual Elements Used in a Monolithic Design	449
16.4.3	System Integration: Design Strategies and Interfacing	456
16.4.4	Illustration: Micro-Displacement Sensors and Micro-Force Sensors	456
16.5	Summary, Benefits, Future Prospects, and Challenges.....	464
	References	464

17	Ultrashort Laser Welding and Joining	467
	Wataru Watanabe, Takayuki Tamaki, and Kazuyoshi Itoh	
17.1	Introduction	467
17.2	Laser Welding	468
17.3	Ultrashort Laser Welding of Transparent Materials	469
17.3.1	Ultrashort Laser Welding with Low-Repetition Rate	469
17.3.2	Ultrashort Laser Welding with High-Repetition Rate	473
17.4	Outlook and Conclusions	474
	References	476
Index		479